Effect of Manganese Doping Percentage on Band Gap Energy of Cadmium Sulphide (CdS) Nanofilms Prepared by Electrodeposition Method

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Abstract: Cadmium sulphide (CdS) nanofilms with different Mn percentage doping were prepared by electrodeposition method at room temperature using aqueous solution of cadmium chloride, manganese chloride, sodium thiosulphate and triethanolamine as the complexing agent. The XRD studies showed that the Mn doped CdS nanofilms have cubic structure with crystallite sizes of range 0.288 to 2.739nm. The thickness of the films determined by optical method were ofrange 2.04nm to 20.82nm. The band gap energy of CdS nanofilms increased with the increasing of Mn percentage doping and their values of range 2.02eV to 2.35 eV were slightly lower than 2.42eV, the literature value for bulk CdS. The observed decrease in band gap energy values of CdS films with different Mn percentage doping may be due to sp-d exchange interaction between the band electrons and localized d-electrons of Mn ions substituting Cd2+ ions. Such Mn doped CdS films could be suitable for applications in thin films solar cells fabrications, photo-thermal and optoelectronic devices.

Keywords: Effect of Manganese percentage doping, bandgap energy, Cadmium sulphidenanofilms, Electrodeposition

1. Introduction

Recently, there has been an increase in research and development of nanostructured II-VI semiconductor materials owing to their importance in basic scientific researches and potential technological applications [1]. Such nanostructured materials exhibit unusual physical and chemical properties in comparison with their bulk materials, such as size dependent variation of band gap energy and have many potential applications in photochemistry, catalysis and electronic/optical materials [2,3].

Cadmium sulphide (CdS) as an important II-VI semiconductor with direct band gap of 2.42eV at room temperature is a promising candidate for solar cells, green lasers, photodetectors, light emitting diode and thin film transistors, photochemical catalysis, gas sensors, detectors for laser and infrared, display screen, nonlinear optical materials, various luminescence devices, optoelectronic devices and so on [1,2,4,5,6,7,8,9,11,12,13,14]. Optical constant as an input data in design process of the thin film devices gives the designer an additional tool for optimization of the product design, thus an accurate knowledge of optical constant over wide range of wavelength is essentially important [7].

Transition metal doped semiconductors known as dilute magnetic semiconductors, have attracted wide spread scientific attention due to their prospective applications. The doping of transition metals (such as Mn, Fe, Co, Ni) into II – VI semiconductors has led to unique optical, electrical, chemical and mechanical properties which cannot be found in undoped materials [15]. Dilute magnetic semiconductors (DMSs) offer great opportunity to integrate electrical, optical and magnetic properties into a single material which makes them ideal candidate materials for nonvolatilite memory, magneto-optical, optoelectronics and futurespintronics devices [1]. Group II – VI semiconductor chalcogenides, such as Cadmium sulphide, owing to its wide band gap energy, is found suitable for use as host material for variety of transition metal dopants [1].

2. Literature Review

The optoelectronic properties, particle sizes and morphologies of nanomaterials have close relation to preparation conditions [11]. Cadmium sulphide can exist in form of stable hexagonal phase or cubic phase or a mixed phase [5]. Cadmium sulphide with cubic structure had been reported by many authors [6,10,16]. The transmission of light through doped CdS films decreases with increasing film thickness and dopant concentration [17,18]. A shift for absorption edge towards the shorter wavelength with increase in doping concentration has been reported [17,18,19,20]. Decrease in band gap can be attributed to the influence of various factors such as grain size, structural parameters, carrier concentration, presence of impurities, deviation from stoichiometry of the film and decrease in the lattice strain [17].

Doping semiconductors with transition metal ions opens up possibilities of forming a new class of materials and new properties of the materials are expected. Transition metals are most interesting impurities as they introduce deep levels in the gap region, which can influence not only optical characteristics but also electrical and magnetic properties thereby influencing their practical applications [20]. Dilute magnetic semiconductors provide the possibility of tuning parameters such as band gap and lattice constants by varying the composition of the material [19]. The variation in band gap can be due to the influence of the various factors such as grain size, structural parameters, carrier concentration, presence of impurities, deviation from stoichiometry of the film and decrease in the lattice strain [17]. The decrease in optical and magnetic parameters, carrier concentration, presence of impurities, deviation from stoichiometry of the film and decrease in the lattice strain [17].
the band gap energy reported for transition metal-doped CdS material can be ascribed to sp-d exchange interaction between the band electrons and localized d-electrons of dopant ions substituting Cd$^{2+}$ ions [16]. Controlling the size and dimensionality of DMS structures is an additional powerful way to tune their properties via quantum confinement effects [21].

Different deposition methods had been reported for cadmium sulphide (CdS) thin films, but solution growth techniques are probably the most explored approach. In this work, electrodeposition method was adopted for the preparation of manganese doped cadmium sulphide (CdS:Mn) nanofilms. Electrodeposition method does not require high temperature and pressure selectivity [5]. Furthermore, this method is scalable with high degree of controllability and reproducibility, hence it is widely applied commercially [22]. The electrodeposition process involves multiple reactions which include reduction, formation and crystallization, (Sharma et al., 2004). The main purpose of this study is to investigate the effect of manganese percentage doping on the band gap energies of CdS nanofilms prepared by electrodeposition method and to proffer the possible applications of such DMS nanofilms.

3. Materials and Method

All the chemical used for the cathodicelectrodeposition of manganese doped cadmium sulphide (CdS:Mn) nanofilms were of analytical grade and all solutions prepared in de-ionized water (Alpha-Q-millipore). The CdS:Mn nanofilms were prepared from acidic bath containing aqueous solutions of 10ml of 0.05M cadmium chloride (CdCl$_2$·2½H$_2$O) as Cd$^{2+}$ ions precursor, 10ml of 0.05M manganese chloride (MnCl$_2$·4H$_2$O) as Mn$^{2+}$ ions precursor, 10ml of 0.05M sodium thiosulphate (NaS$_2$O$_3$·5H$_2$O) as S$^{2-}$ ions precursor, 10ml of 0.05M tri-ethanolamine (TEA) as complexing agent. Few drops of 1.0M hydrochloric acid (HCl) were used to control the PH of the electrolyte in the reaction bath. Prior to deposition, the ITO glass substrates were degreased with ethanol for 10 minutes; then ultrasonically cleaned with de-ionized water for another 10 minutes and finally dried in a desicator. The surface of the platinum plate was thoroughly polished and all glass beakers / measuring cylinders thoroughly washed with de-ionized water.

The experiment was carried out using acidic bath of PH 3, at room temperature, optimum deposition time of 240 seconds and optimum deposition voltage of 4.0 Volts while manganese doping percentage in the reaction bath was varied from 3% to 23%. The reactions involve chelating of Cd$^{2+}$ and Mn$^{2+}$ ions with complexing agent, tri-ethanolamine to form a complex ions, CdMnTEA$^{2+}$ which then react with the S$^{2-}$ ions produced from sodium thiosulphate solution to form CdMnS compound at the cathode (ITO glass substrate). The deposited CdS: Mn films were rinsed with de-ionized water, dried, annealed at the temperature 250 °C and kept for analysis.

The structural analysis of Mn doped CdS nanofilms was studied by X-ray Mini Diffractometer, model MD 10. The optical studies of manganese doped cadmium sulphidenanofilms were carried out by JENWAY 6405 UV-Vis Spectrophotometer within the wavelength range of 280nm to 1100nm. The absorption coefficient α of the film samples is determined by the equation:

\[ \alpha = \frac{A}{\lambda} \]  

where A is the absorbance of the film and \( \lambda \) is wavelength of incident radiation.

Near the absorption edge the absorption coefficient is related to the band gap, \( E_g \) by the equation:

\[ \alpha = (h\nu - E_g)^b \]  

where \( h \) is the Planck’s constant, \( U \) is the frequency of incident radiation, \( h\nu \) is the photon energy and \( b \) is a constant for a given transition.

The band gap energy (\( E_g \)) of the films are respectively obtained from allowed transition by extrapolating the graph of \( \alpha^2 \) versus \((h\nu)\) to the point where \( \alpha^2 \) is zero.

4. Results and Discussion

The XRD pattern of the CdS:Mn film (with 8% Mn) deposited on ITO glass substrate is shown in Fig. 1. The crystals of CdS:Mn film were of cubic structure with preferential growth along (400) direction and lattice constant of \( a = b = c = 10.176 \) Å. The crystallite size of the film sample calculated using Debye-Scherrer’s formula ranged from 0.2878nm to 2.7386nm with mean crystallite size of 1.1394nm.

![Figure 1: XRD pattern CdS:Mn with 8% MnMn doping](image-url)
The mean dislocation density value 6.2403 and microstrain of 0.739 may be attributed to interstitially substituted Mn impurity atoms or due to adsorbed colloidal Cd in the film samples. Similar CdS cubic structure had been reported for CdS prepared using cadmium complex compounds and thioacetamide[10],CBD method at a temperature of 80°C and co-precipitation method [16].

The thickness of the Mn doped CdS films determined using optical method ranged from 2.04nm to 20.82nm confirming the nanometer size of the film samples. The transmission spectra of Mn doped CdS:Mn nanofilms (with different Mn percentage doping) are shown in Fig. 2.

![Figure 2: Transmittance spectra of ZnS:Mn films with different Mn doping%](image)

All the films have high transmittance (>70%) beyond the absorption edge. At wavelength of 550nm in the visible region, the average transmittance of the CdS:Mn film samples increased from 0.87 to 0.88 as Mn doping % increased from 3% to 18% and then decreased to 0.80% as Mn doping % increased to 23%. The high transmittance of the film samples may be ascribed to the thinness of the films. The optical absorption spectra of CdS:Mn films with different Mn percentage doping are shown in Fig. 3.

![Figure 3: Absorption spectra of ZnS:Mn films with different Mn doping%](image)

The absorption coefficient (α) of all the CdS:Mn films were relatively high in the wavelength range of 300 – 350nm and zeroed from the wavelength of 700nm. At wavelength of 550nm in the visible region, the average absorption coefficient of Mn doped CdS films decreased from 0.25 x 10^6 to 0.10 x 10^6 as Mn doping % increased from 3% to 8% and then increased to 0.25 x 10^6 as Mn doping % increased to 23%. However, the film sample doped with 18% Mn (P2C4) exhibited low absorption coefficient of 0.10 x 10^6. The obtained magnitude of absorption coefficient 10^6 is within the range of 10^6 to 10^7 required for the fabrication of semiconductor thin film solar cells [24]. The absorption edge of all the CdS:Mn films fall within the shorter wavelength range 300nm-320nm compared to 515nm reported for bulk cubic CdS, thus suggesting that they are blue shifted.[10]. The blue shift in absorption edge may be attributed to quantum confinement of the excitons present in the film samples, resulting in a more discrete energy spectrum of the individual particles [2]. Similar results had been reported for Cu,Fe co-doped CdS [1], Mn,Ce co-doped CdS,[11], Mn - doped CdS [4] and Cl - doped CdS films.[17] Such films with high absorption coefficient in the visible region could be employed as widow materials in various photo-thermal and optoelectronic devices [1,25].

The optical band gap values of CdS:Mn nanofilms were obtained by extrapolating the linear part of the curves of α^2 versus hν to hν = axis where α = 0 as shown in Fig. 4.
The band gap energy of CdS nanofilms increased from 2.02eV to 2.35eV as Mn doping % increased from 3% to 18% and then decreased to 2.12eV as Mn doping % increased to 23%. The highest optical band gap value (2.35eV) was obtained from the film sample (P2C4) doped with 18% Mn. These results revealed that the band gap energy values of the CdS:Mn nanofilms of range 2.02eV to 2.35eV were lower than 2.42eV reported for undoped CdS [5] but compare favorably with the band gap energy range 2.30eV to 2.38eV reported for Mn doped CdS films prepared by chemical bath deposition method [4], 2.36eV for mercury doped CdS [25], 2.20eV for Cu, Fe co-doped CdS [1] and 2.35eV for undoped CdS [7]. Although the obtained band gap values are lower than the CdS, bulk value, their value increase with the increasing of percentage doping. The decrease in the band gap energy observed in the doped CdS nanofilms may be due to sp–d exchange interaction between the band electrons and localized d-electrons of Mn ions substituting Cd $^{+2}$ ions [16].

The difference in the band gap energy values of CdS with different Mn content confirmed that Mn doping % strongly influenced the band gap energy of the film samples. Such direct band gap Mn doped CdS nanofilms with a wide range of band gap energy values could be employed for the thin films solar cells fabrications and various optoelectronic devices applications [1,2,4,5,7].

5. Conclusion

Manganese doped cadmium sulphide (CdS:Mn) nanofilms were successfully prepared by electrodeposition method using acidic bath containing aqueous solution of cadmium chloride, manganese chloride, sodium thiosulphate and a complexing agent, triethanolamine. The XRD pattern of CdS:Mn nanofilms revealed that the crystals of the film have cubic structure. The thickness of the films were found to be in nanometer sized range. We investigated the effect of manganese percentage doping on band gap energy of CdS nanofilms. The results showed that the obtained band gap energy values were lower than 2.42 eV reported for the undoped bulk CdS but increase with the increasing of Mn percentage doping. Such CdS:Mn nanofilms with wide range of direct band gap energy values could be employed for thin films solar cells fabrications and various optoelectronic devices applications.

We recommend that more research work be carried out on Mn doped CdS nanofilms using other methods of deposition.

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